

Fundamentals of Nanotransistors

Unit 1: Transistor Fundamentals

Lecture 1.1: Course Introduction

Mark Lundstrom

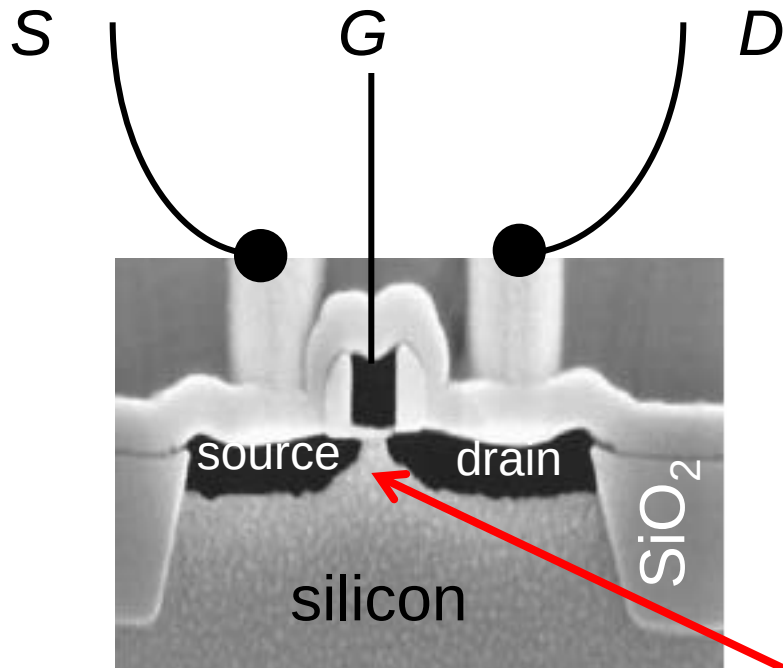
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Electrical and Computer Engineering

Birck Nanotechnology Center

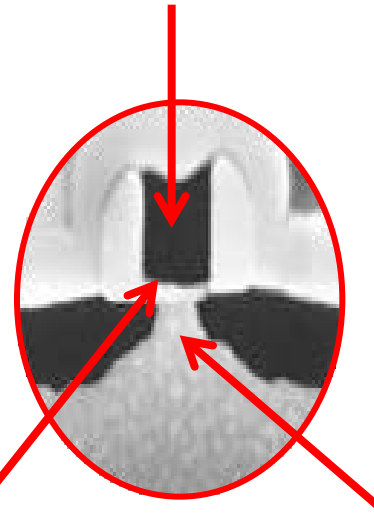
Purdue University, West Lafayette, Indiana USA

Silicon MOSFETs



1960's: $L \sim 10,000$ nm

gate
electrode



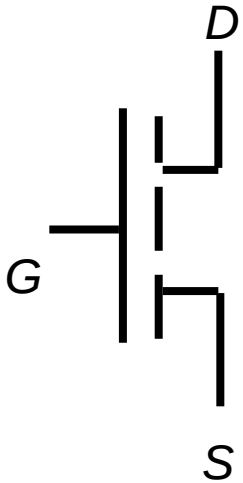
(Source: Texas Instruments, ~ 2000)

gate oxide
EOT ~ 1.1 nm

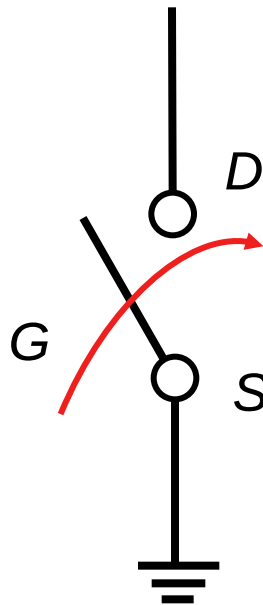
channel
 ~ 20 nm

Transistors

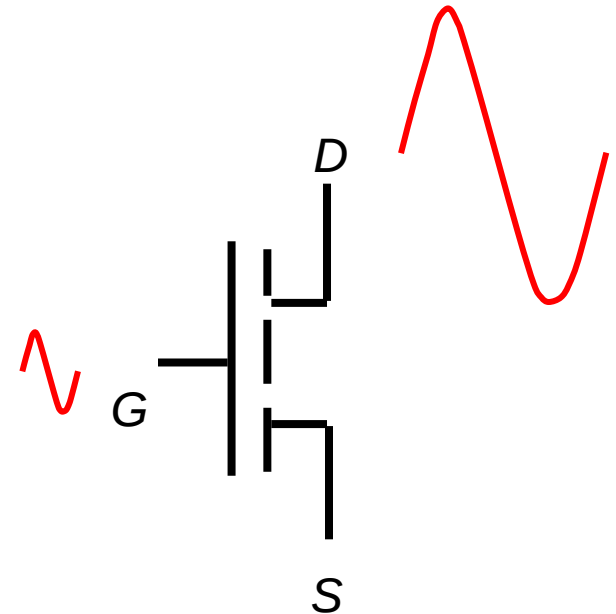
symbol



switch



amplifier

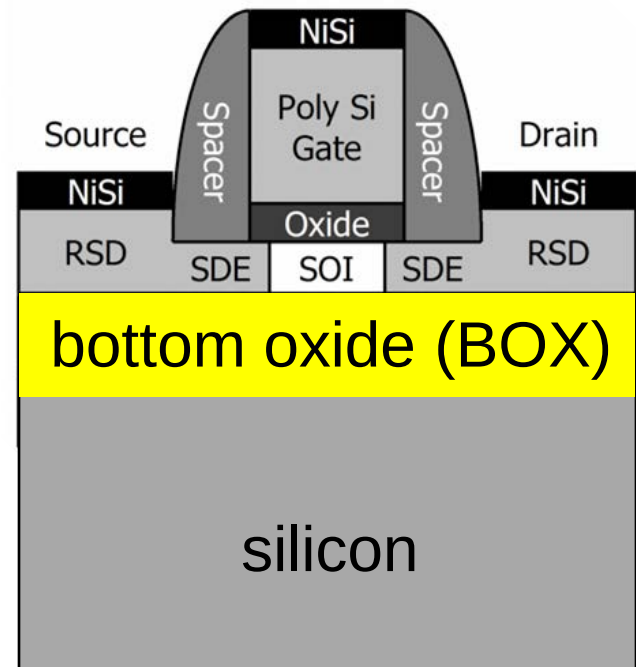


digital electronics

analog electronics

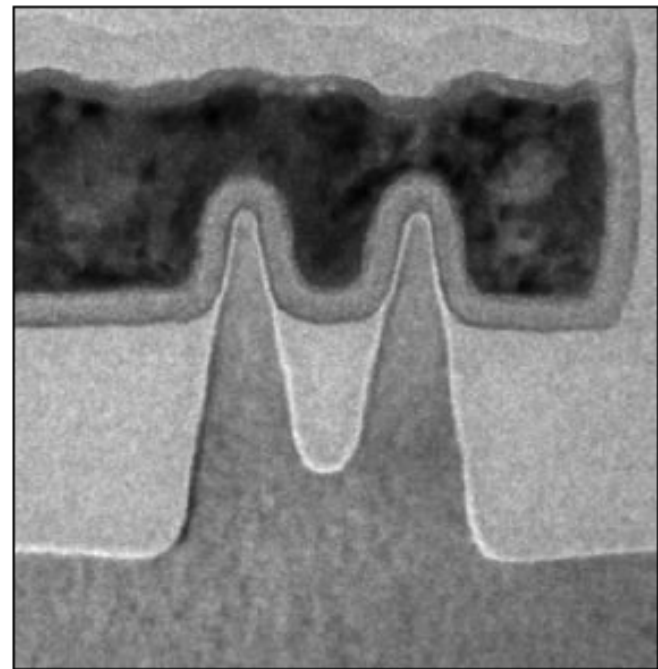
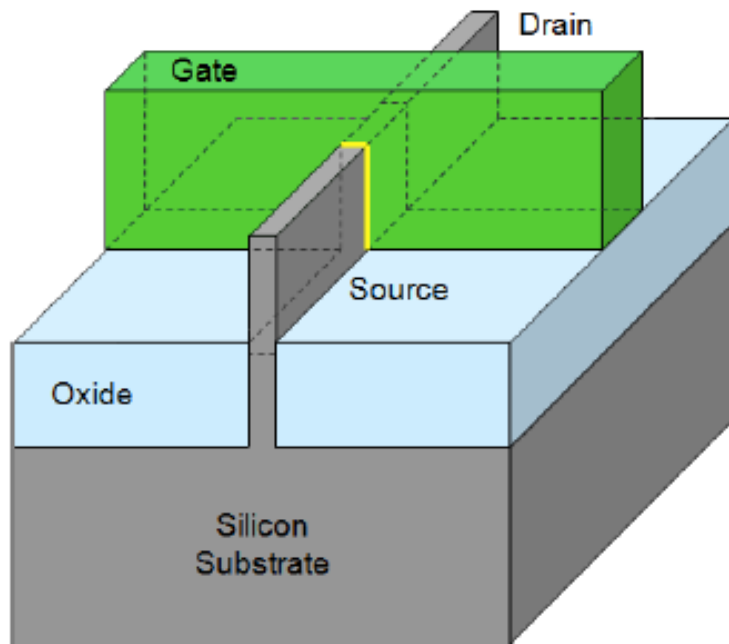
SEM image of a device structure. Labels include *S*, *G*, *D*, source, drain, silicon, and SiO_2 .

Extremely Thin Silicon On Insulator (ETSOI) MOSFET

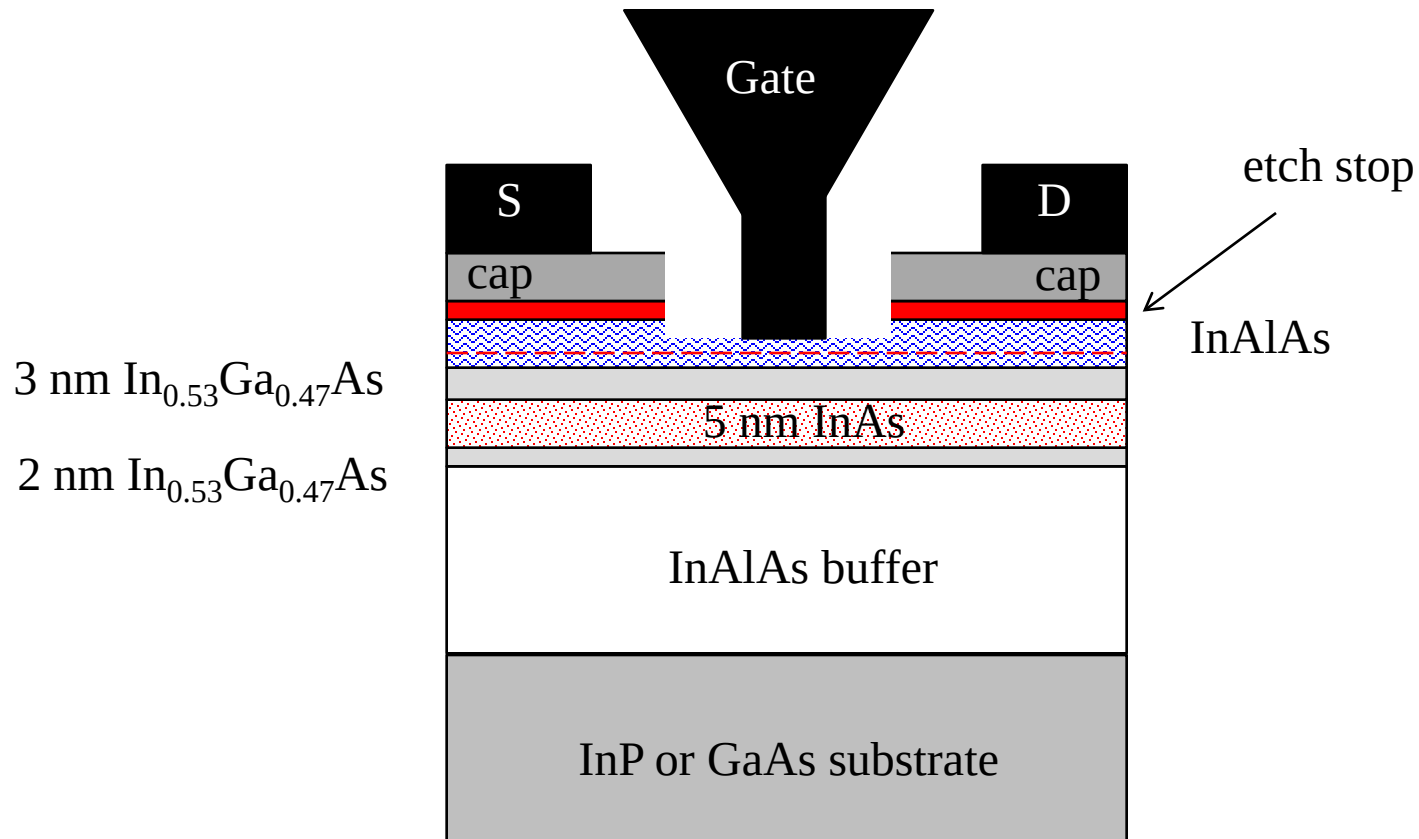


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Modern MOSFETs: FinFETs

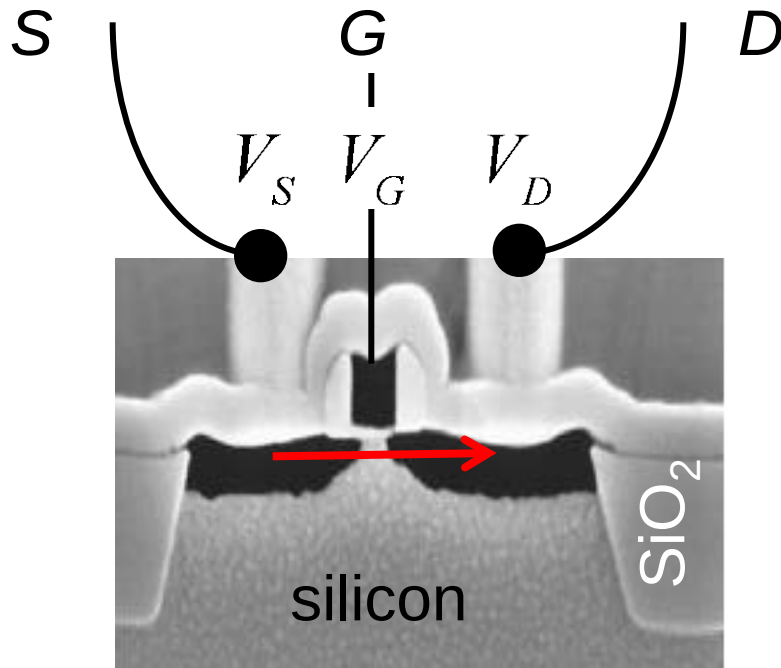


III-V FETs: HEMTs and MOSFETs

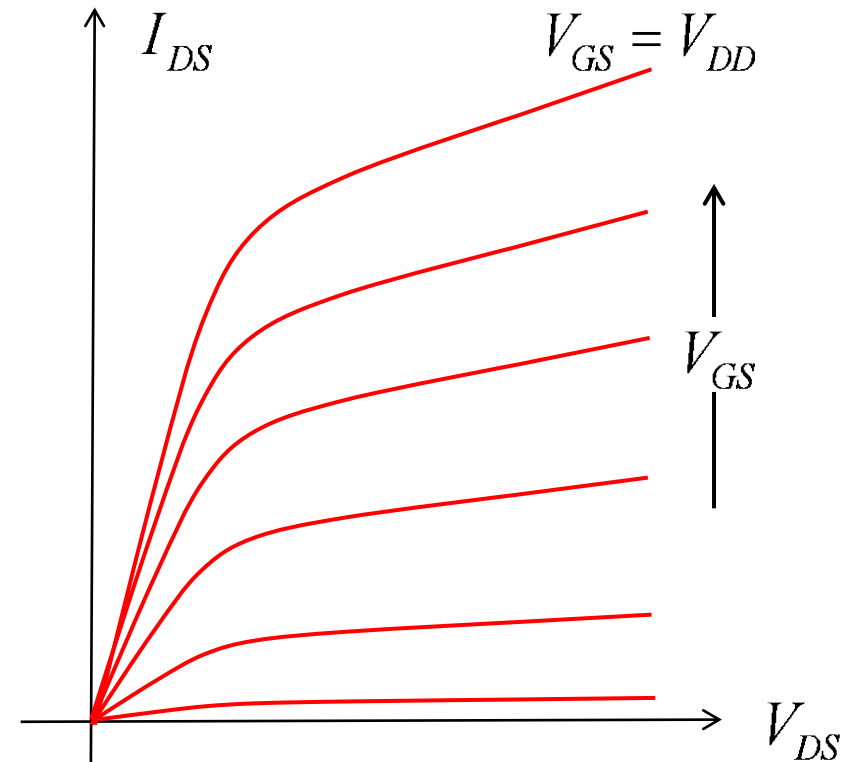


(after J. del Alamo, MIT)

Course objectives



(Source: Texas Instruments, ~ 2000)



1) Understand the physical operation of nanoscale transistors.

2) Relate that physical understanding to the I/V characteristics.

Course outline

Unit 1: Transistor fundamentals

Unit 2: MOS electrostatics

Unit 3: The ballistic MOSFET

Unit 4: Transmission theory of the MOSFET

Prerequisite: Understanding of basic semiconductor physics.

Unit 1: Transistor Fundamentals

- Lecture 1.1: Introduction
- Lecture 1.2: The MOSFET as a Black Box
- Lecture 1.3 MOSFET Device Metrics
- Lecture 1.4 Transistors to Circuits
- Lecture 1.5 Energy Band View of Transistors
- Lecture 1.6 Traditional IV Theory
- Lecture 1.7 The “Virtual Source Model”
- Lecture 1.8 Unit 1 Summary

Please ask questions!

Additional resources

Links to relevant on-line resources will be provided.

(e.g. “Quick Review of Semiconductor Physics”)

A draft set of lecture notes to be published by World Scientific will also be provided to students of this course.

Please ask questions!